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## Correction: Three-dimensional hierarchical Te–Si nanostructures

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Correction for 'Three-dimensional hierarchical Te–Si nanostructures' by Jae-Hong Lim *et al.*, *Nanoscale*, 2014, 6, 11697–11702.

The correct text in the Acknowledgements section should be:

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The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

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